



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

September 30, 2025

IGI Report Number

LG734518734

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

EMERALD CUT

Measurements

9.87 X 6.74 X 4.57 MM

GRADING RESULTS

Carat Weight

3.02 CARATS

Color Grade

FANCY INTENSE PINK

Clarity Grade

VS 2

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

STRONG

Inscription(s)

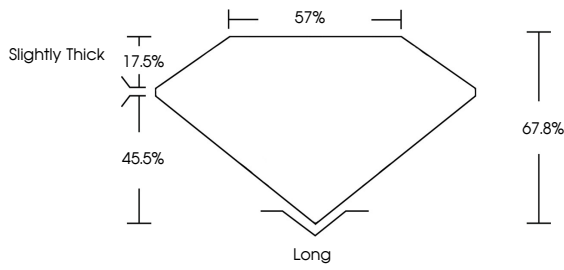
 LG734518734

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Indications of post-growth treatment.

LG734518734

Report verification at [igi.org](https://www.igi.org)

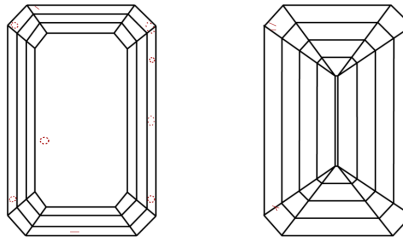
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

IF VS ¹⁻² VS ¹⁻² SI ¹⁻² I ¹⁻³

Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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EMERALD CUT

3.02 CARATS

FANCY INTENSE PINK

VS 2

67.8%

57%

Slightly Thick

Long

EXCELLENT

EXCELLENT

STRONG

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